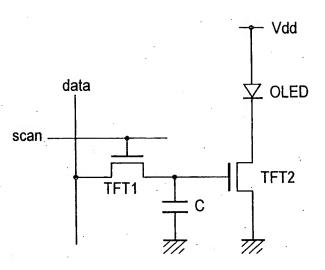
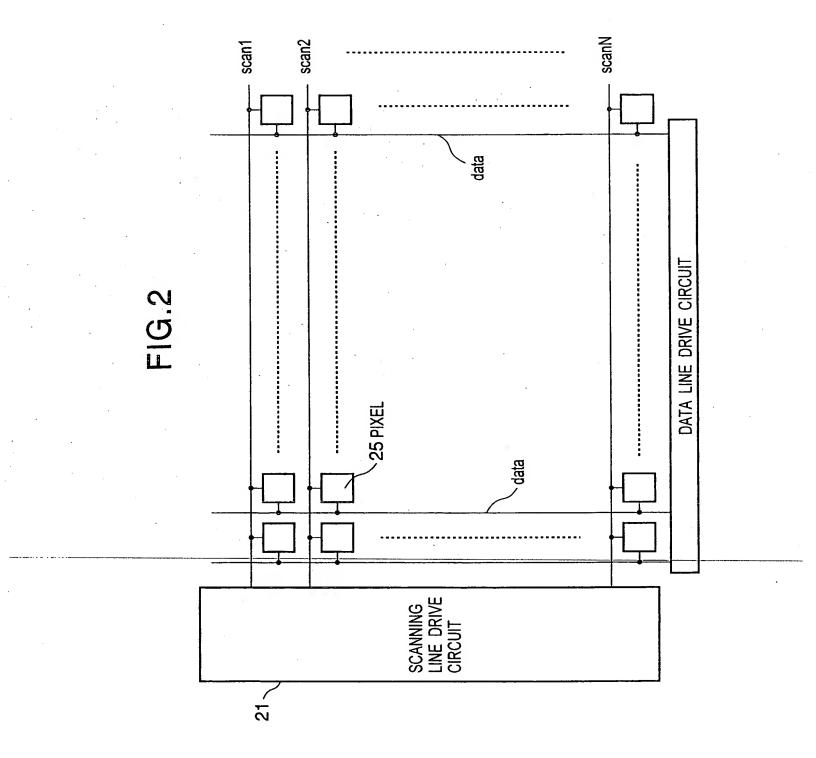
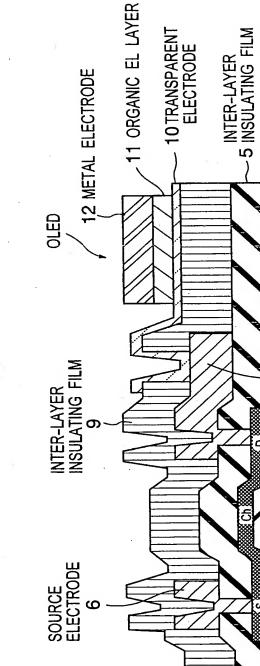
FIG.1







-3 GATE INSULATING FILM 1 GLASS SUBSTRATE INTER-LAYER -5 INSULATING FILM DRAIN ELECTRODE TFT2 SEMICONDUCTOR THIN FILM

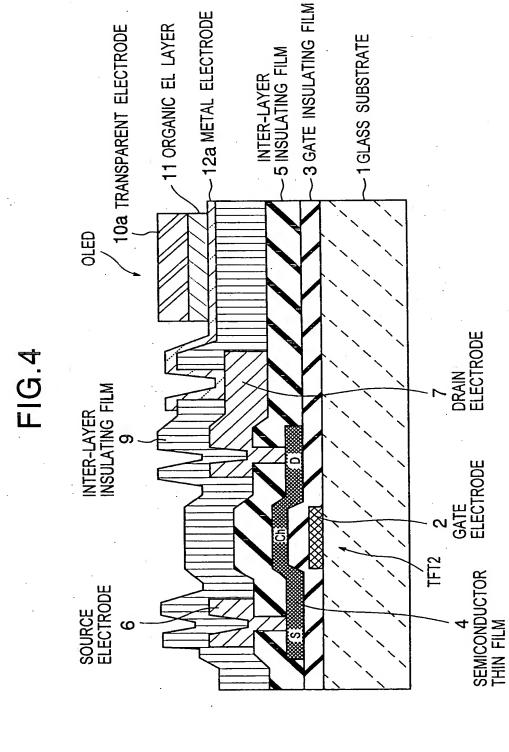
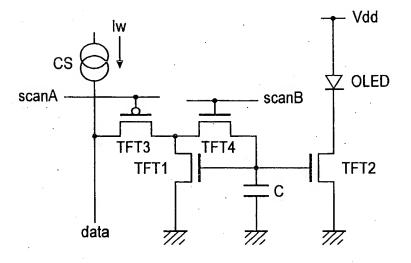
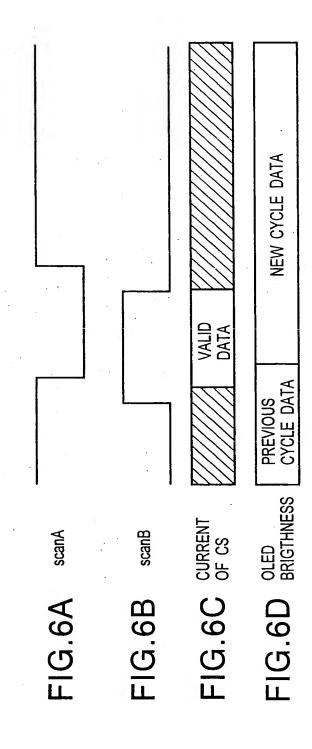


FIG.5





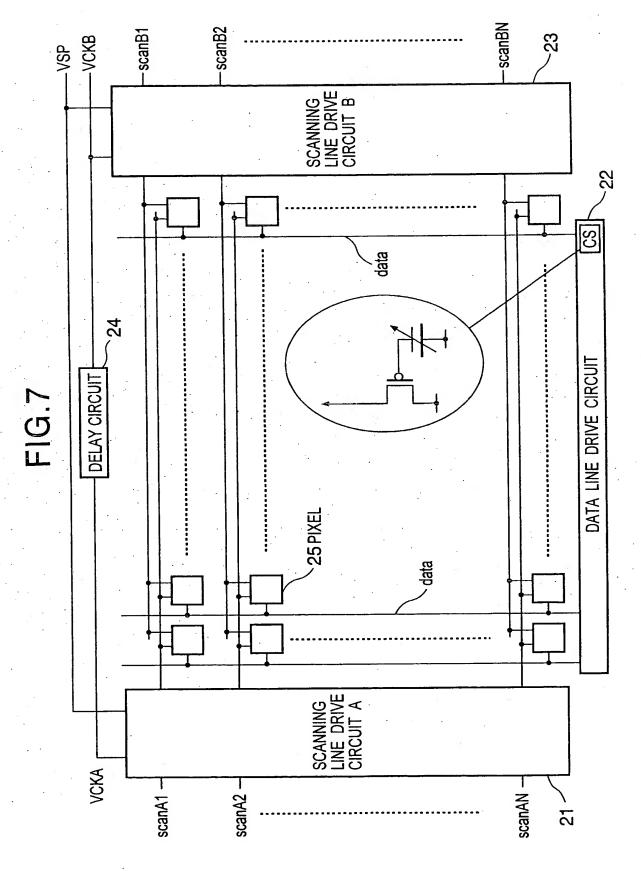


FIG.8

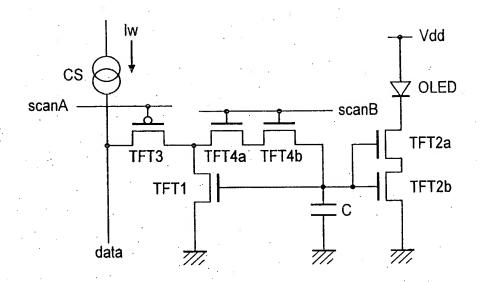
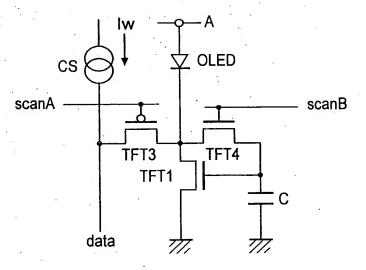


FIG.9



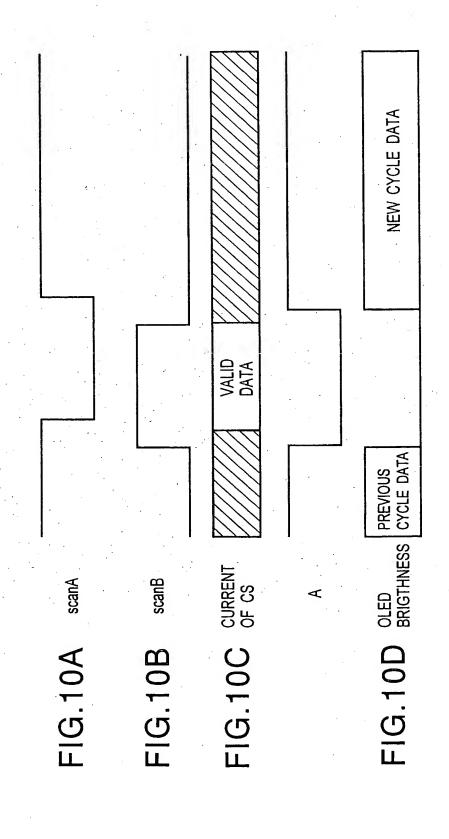


FIG.11

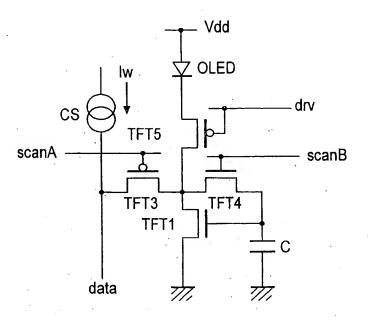


FIG.12

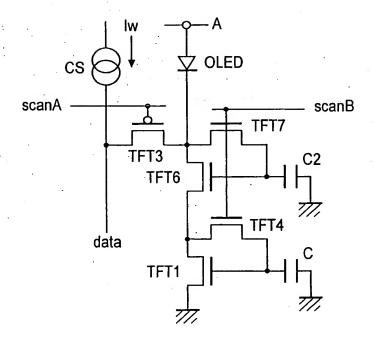


FIG.13

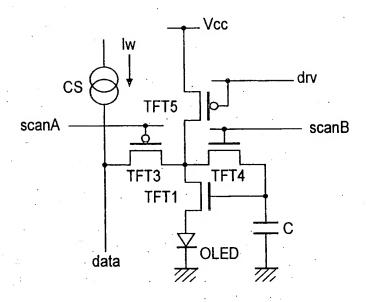


FIG.14

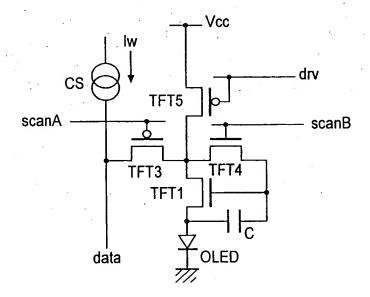


FIG.15

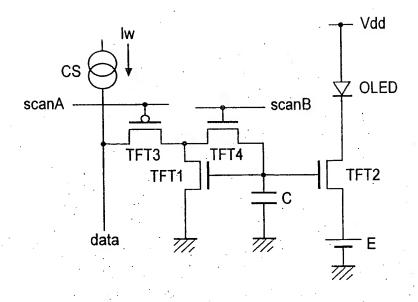
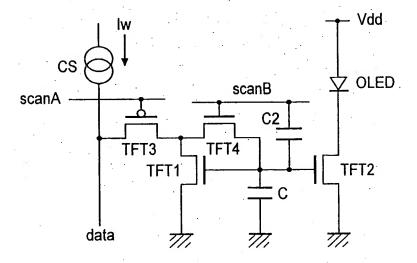


FIG.16



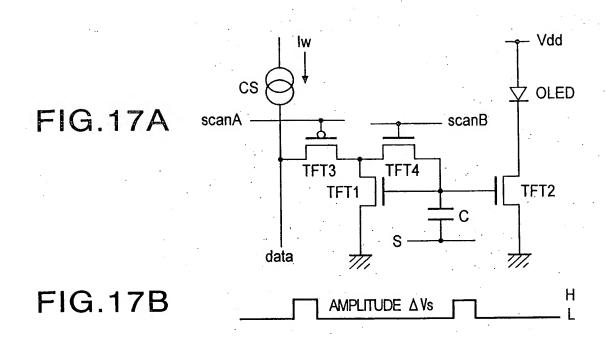


FIG.18

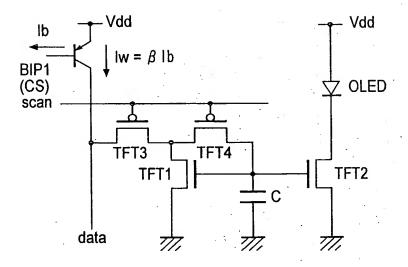
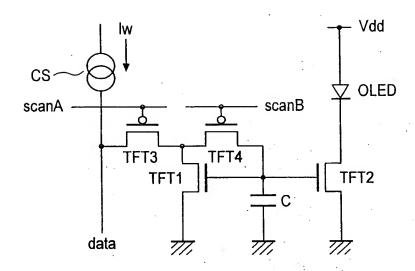


FIG.19



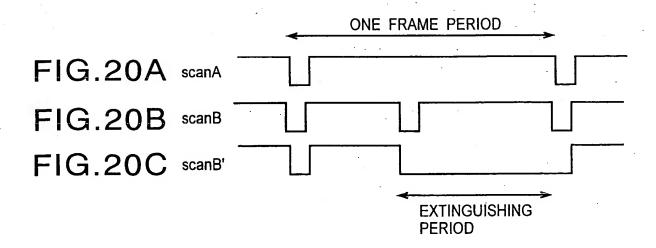


FIG.21

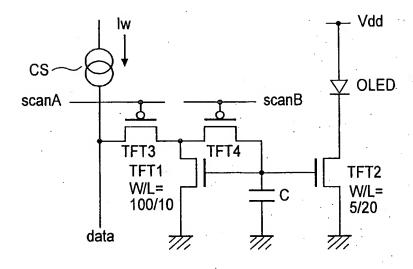


FIG.22

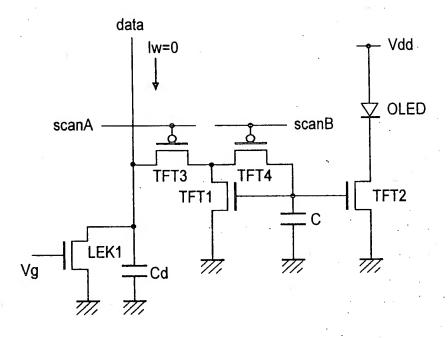


FIG.23

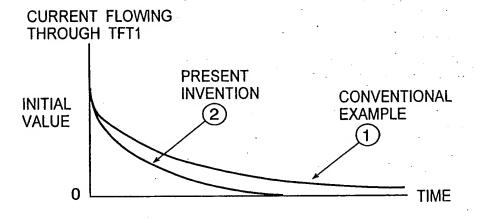


FIG.24

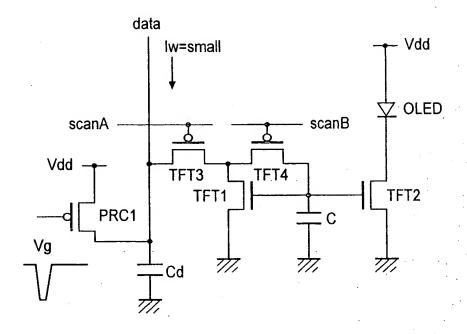


FIG.25

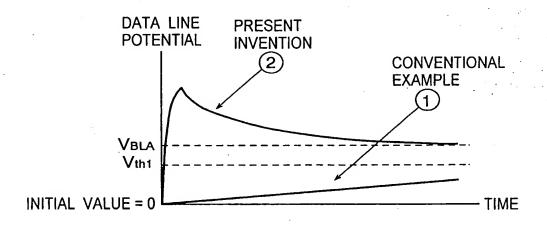


FIG.26

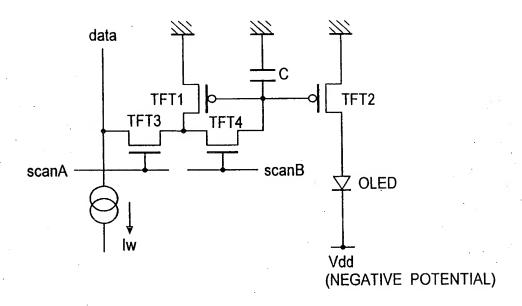


FIG.27

